FORM PTO 1449 (modified) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE LIST OF REFERENCES CITED BY APPLICANT(S) (Use several sheets if necessary)				ATTY DOCKET NO. 00862.023527	APPLICATION NO. 10/812,868			
				APPLICANT TERUYOSHI WASHIZAWA				
(Use several sheets if necessary) Submitted to the PTO: May 26, 2004		MAY 2 6 200	\ \(\frac{1}{2}\)	FILING DATE March 31, 2004	GROUP Unassigned		d	
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^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.